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(12) **United States Design Patent**
Matsumoto et al.

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(54) **BAFFLE PLATE**

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(**) Term: **14 Years**

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(30) **Foreign Application Priority Data**

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(52) **U.S. Cl.**
USPC **D13/182**

(58) **Field of Classification Search**
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118/715, 733; 219/444.1; 414/147, 217,
414/247, 935-941; 438/482, 706, 716, 758;
451/285

See application file for complete search history.

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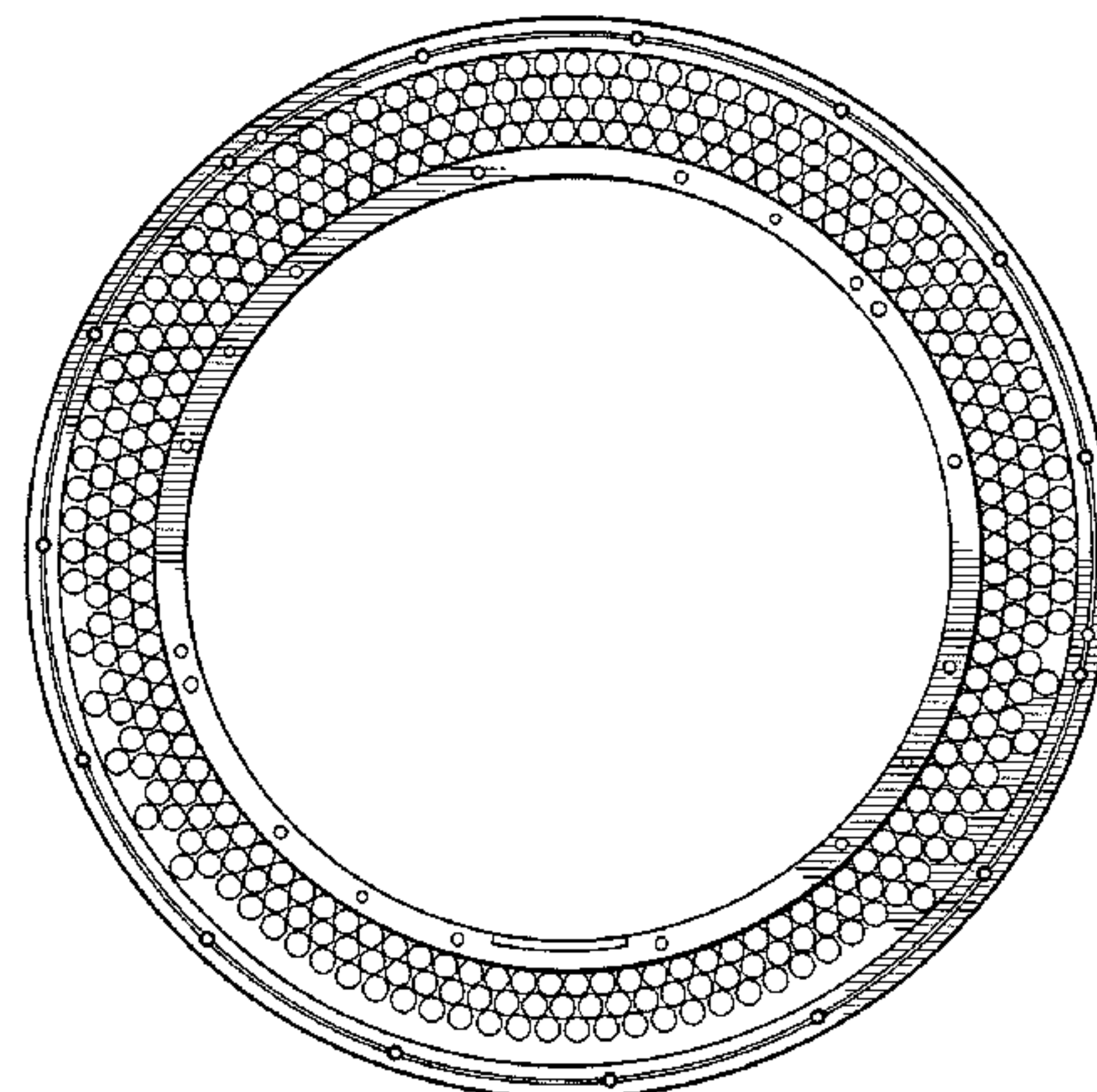
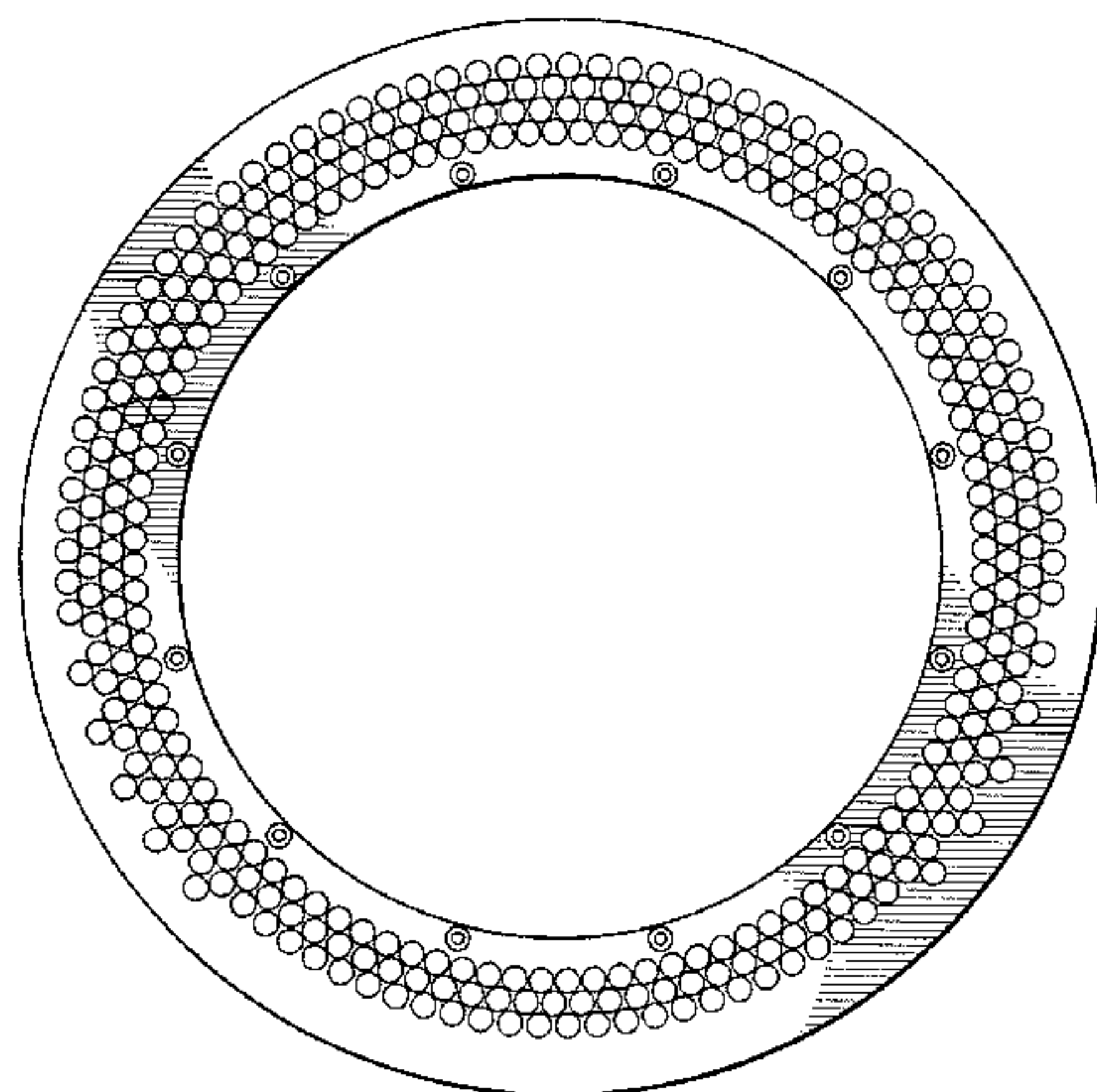
(57) **CLAIM**

The ornamental design for a baffle plate, as shown and described.

DESCRIPTION

FIG. 1 is a front view of a baffle plate showing our new design.
 FIG. 2 is a rear view of the baffle plate of FIG. 1.
 FIG. 3 is a top plan view of the baffle plate of FIG. 1.
 FIG. 4 is a bottom plan view of the baffle plate of FIG. 1.
 FIG. 5 is a right side view of the baffle plate of FIG. 1.
 FIG. 6 is a left view of the baffle plate of FIG. 1.
 FIG. 7 is a front perspective view of the baffle plate of FIG. 1.
 FIG. 8 is a rear perspective view of the baffle plate of FIG. 1;
 and,
 FIG. 9 is a front perspective view of the baffle plate of FIG. 1
 shown in a used condition with a plasma processing device
 shown in broken lines.
 The features shown in broken lines depict environmental
 subject matter only and form no part of the claimed design.

1 Claim, 4 Drawing Sheets



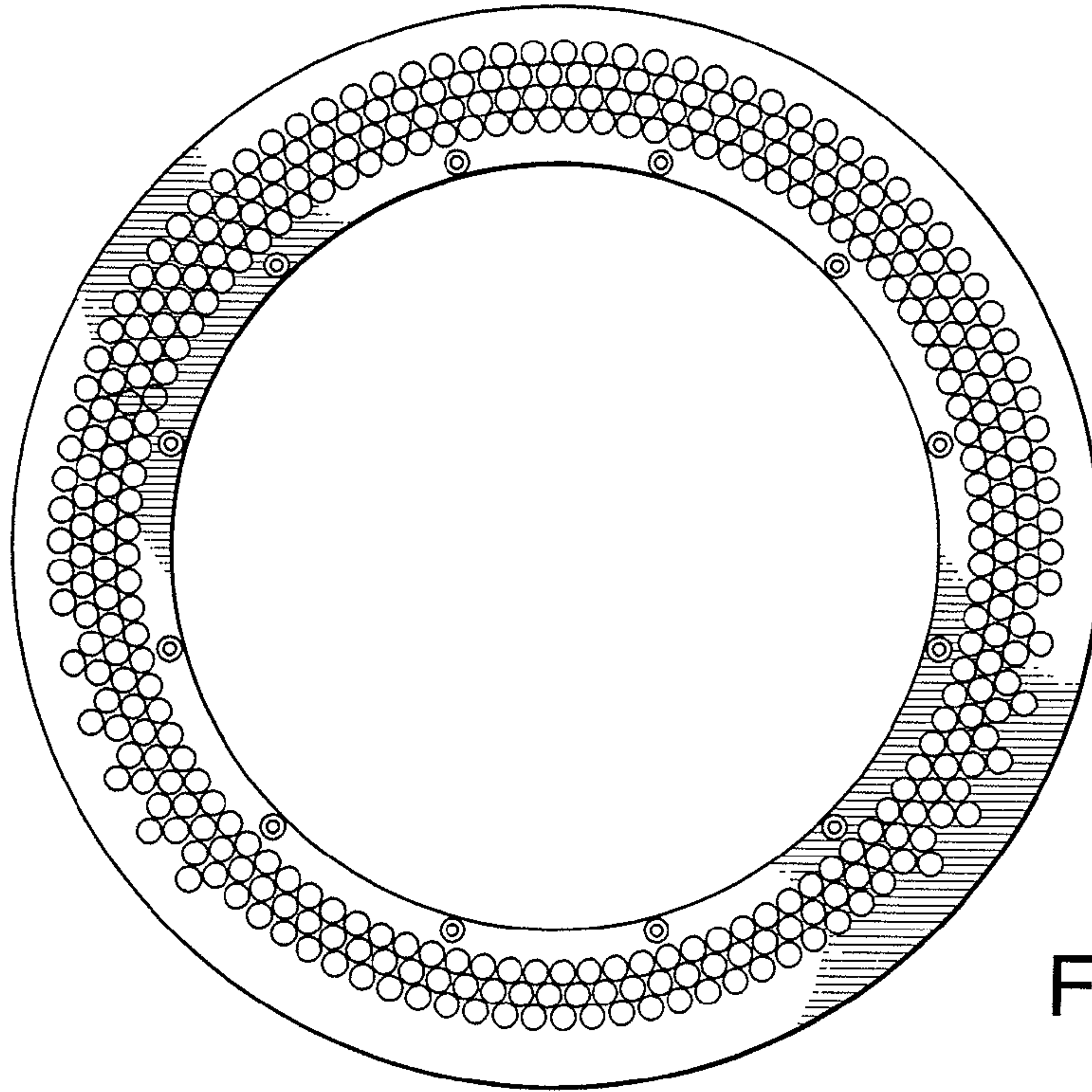


FIG. 1

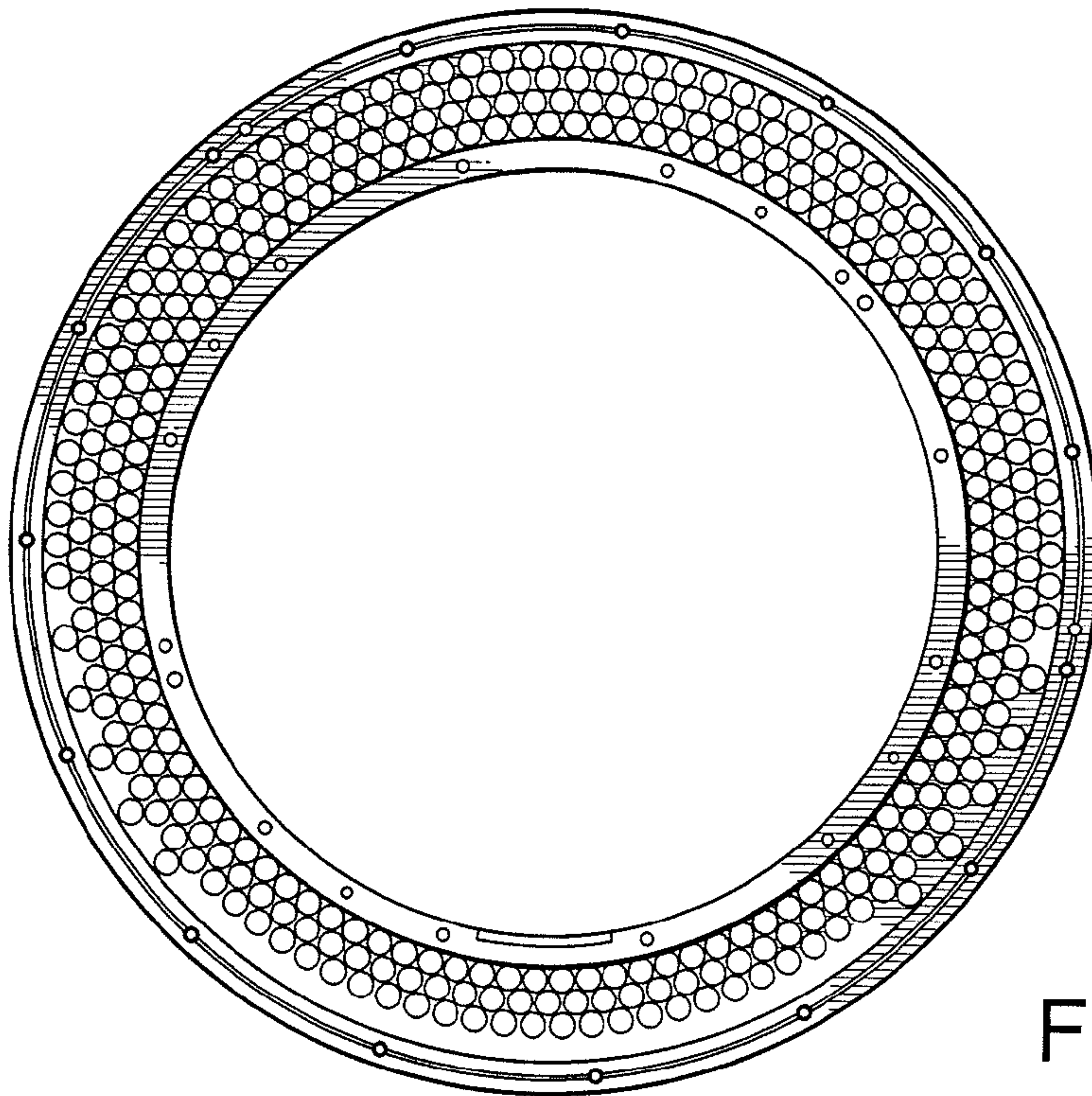


FIG. 2



FIG. 3

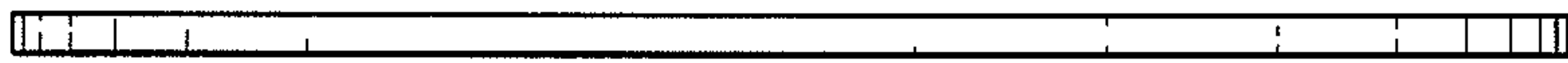


FIG. 4



FIG. 5



FIG. 6

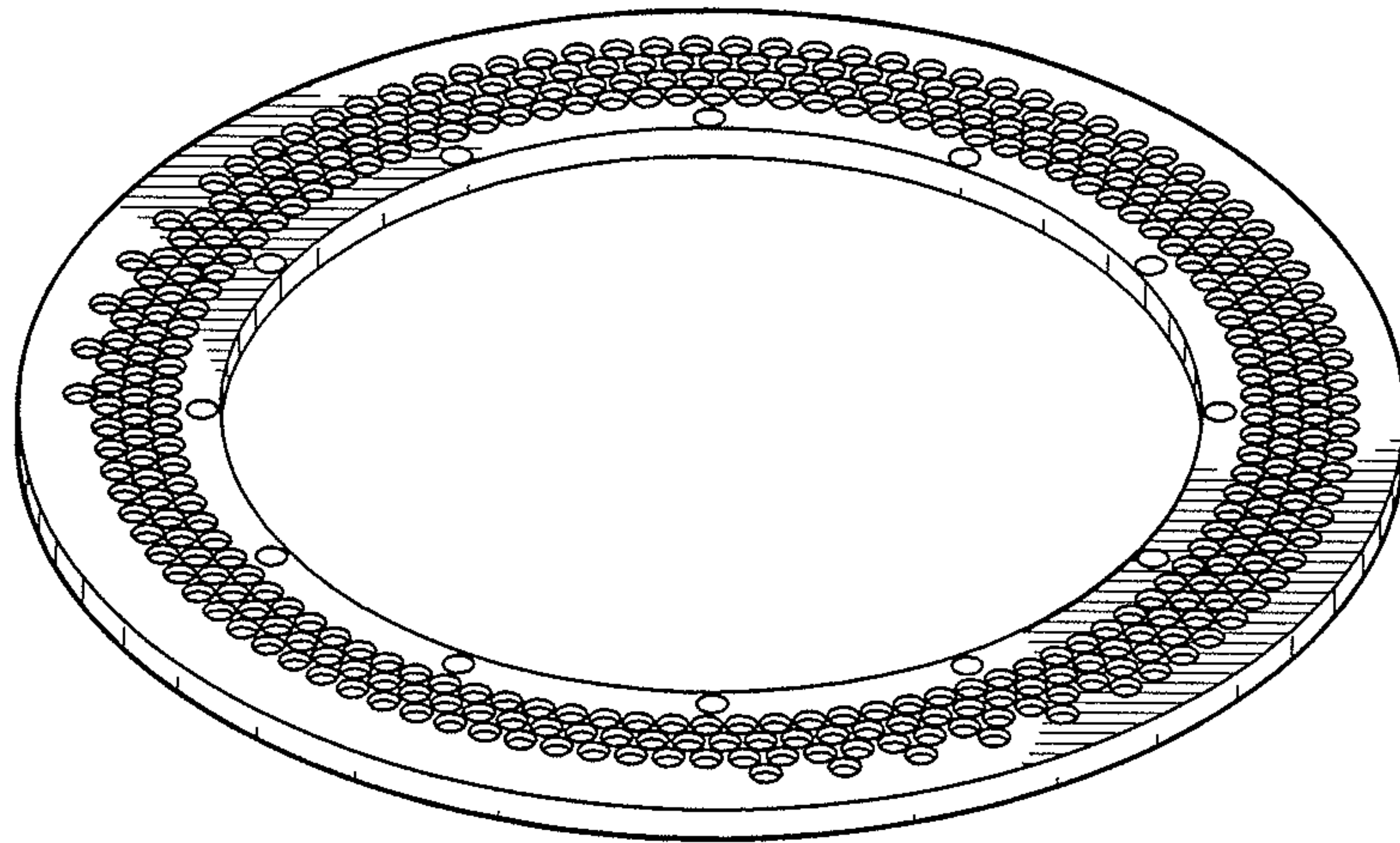


FIG. 7

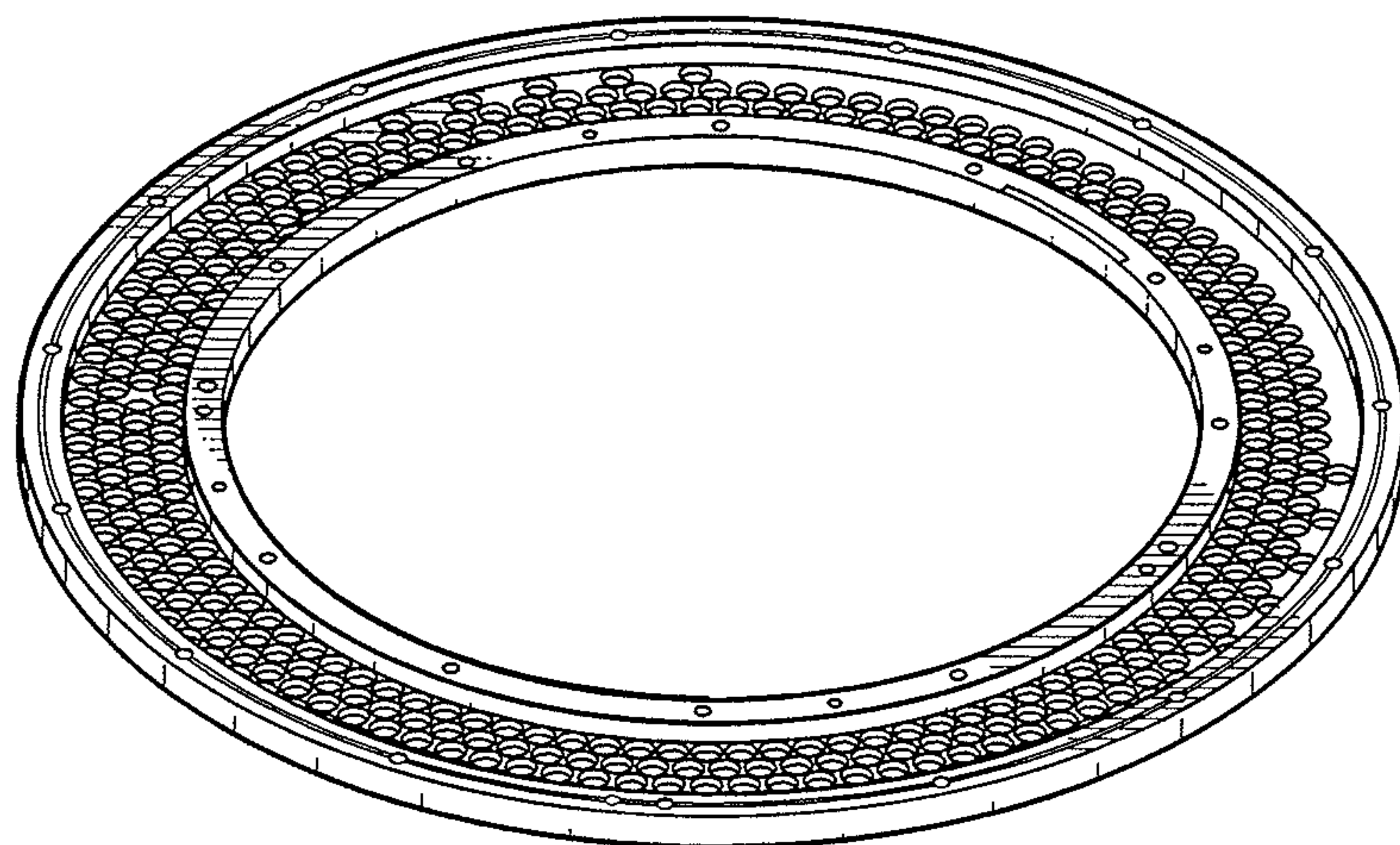


FIG. 8

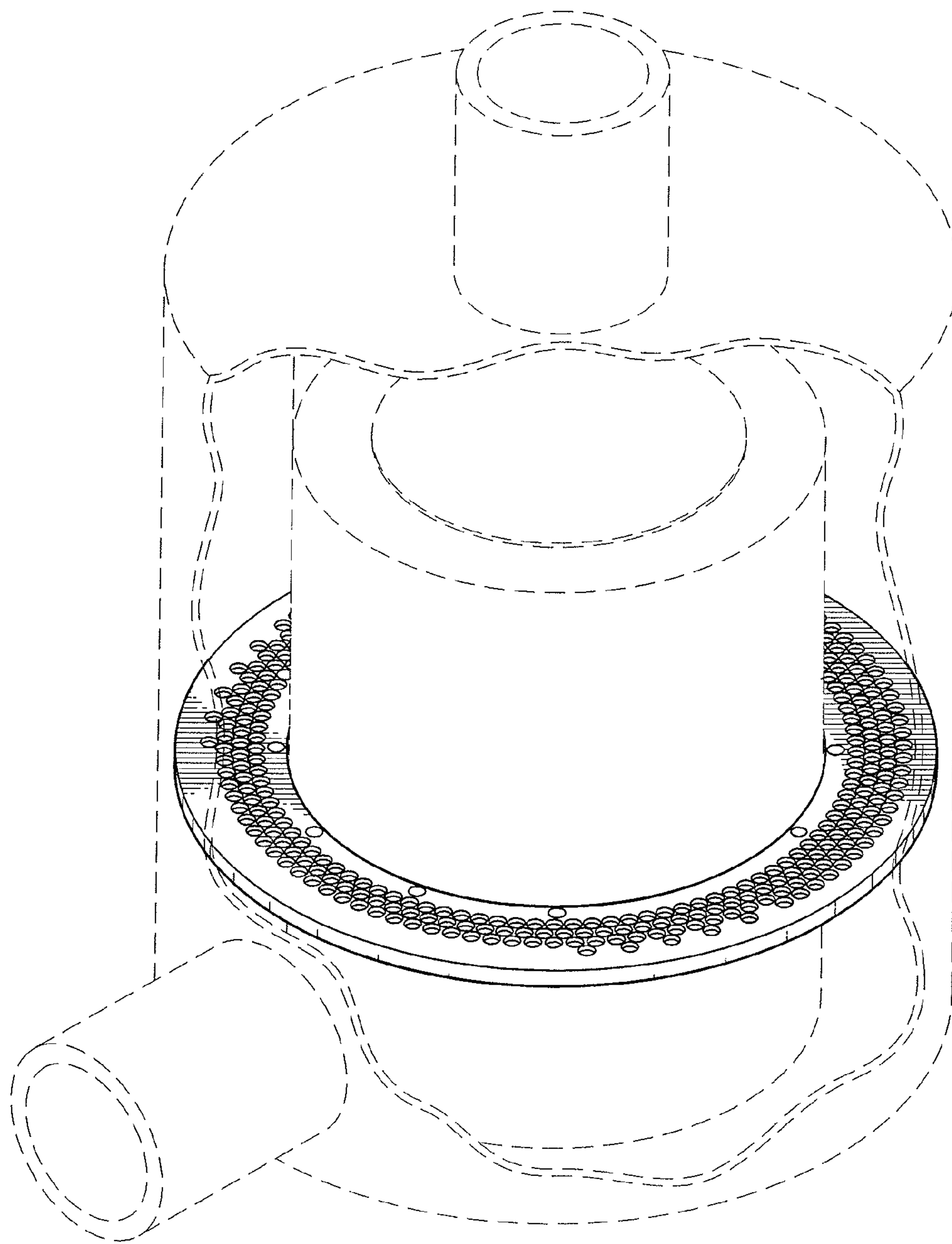


FIG. 9